



Effect of molecular ordering on spin and charge injection in rubrene

K. V. Raman,^{1,*} S. M. Watson,² J. H. Shim,¹ J. A. Borchers,² J. Chang,^{1,3} and J. S. Moodera¹

¹Francis Bitter Magnet Laboratory, MIT, Cambridge, Massachusetts 02139, USA

²National Institute of Standards and Technology, Gaithersburg, Maryland 20899, USA

³Center for Spintronics Research, Korea Institute of Science and Technology, Seoul, Korea

(Received 30 July 2009; revised manuscript received 29 October 2009)

Studies have shown that interfaces play a crucial role for efficient spin injection and transport. Here, we address the complex role of interface in spin and charge injection into organic materials by various interface-sensitive characterization tools. Inelastic tunneling spectroscopy and polarized neutron reflectometry were mainly adopted to explore the interfaces of high mobility organic semiconductor rubrene sandwiched by two ferromagnetic electrodes. The dramatic difference in the reported magnetotransport properties and charge injection characteristics in trilayer magnetic junctions have been attributed to the different growth morphology of rubrene molecules at the interface dictated by the presence or absence of a 0.6 nm alumina seed layer. The magnetic contribution of the top ferromagnetic electrode is also influenced by the morphology of the rubrene layer underneath, directly affecting the spin injection efficiency. This work highlights the importance of interface engineering in the development of organic-based spintronics devices.

DOI: XXXX

PACS number(s): 72.25.Dc, 72.25.Mk, 72.80.Le, 75.47.-m

Spin transport in π -conjugated organic semiconductors (OSs) is necessarily a vast and complex area that is just beginning to be explored.¹ Recent demonstrations of spin transport in organic materials^{2–6} have been promising, giving impetus to explore the potential of OSs in spintronics applications. Although their study can be extremely challenging, it is expected to be rich in knowledge. For instance, unlike inorganic semiconductors, OSs have shown significantly complex charge injection and transport mechanisms. To date, several theories have dealt with the transport phenomena: modeling the strong electron-phonon coupling (polarons) and the structural disorder of the molecules to account for the observed transport characteristics in different organic systems.^{7–9} Growth-related structural changes in OS films have also been known to influence the transport properties¹⁰ and, consequently, the spin injection and transport, as observed in this work. Due to the complexity associated with organic systems, appropriate characterization methods need to be implemented to understand the spin transport.

In our recent work, we demonstrated a large tunneling magnetoresistance (TMR) of 6% at room temperature, showing a spin-diffusion length of 13 nm in thin amorphous rubrene films ($C_{42}H_{28}$).¹¹ The study was performed in the tunnel junction structure for hybrid (rubrene film grown on alumina as tunnel barrier) and rubrene (rubrene film grown without alumina seed layer) barriers. In this work, we address the role of interfaces, their influence on the growth morphology of the OS, and hence on the transport properties by performing interface-sensitive characterization by inelastic tunneling spectroscopy (IETS) and polarized neutron reflectometry (PNR) measurements. Charge and spin transport measurements were extended to thick rubrene barriers (>20 nm) to obtain information on the evolution of the film morphology with thickness in both types of junctions.

Samples for IETS measurements were prepared as a metal-insulator-metal structure with a thin rubrene barrier film to form hybrid junctions (HJs) and rubrene junctions (RJs). The layers were all grown *in situ* using a shadow mask

technique^{3,11} in a deposition chamber with a base pressure of 6×10^{-8} Torr. In the case of HJs, the bottom electrode and a thin Al layer (0.5 nm) were grown at low temperature (80 K). This was followed by short (6–8 s) oxygen plasma exposure (500 W at 60 mTorr) to form a thin alumina seed layer. The rubrene barrier and the top electrode were then deposited at room temperature to form the junction ($200 \times 200 \mu\text{m}^2$).

IETS is a powerful tool to analyze the active vibrational modes of molecules within the barrier, in probing their orientation, structural, electronic, and chemical modifications.^{12,13} The strong electron-phonon coupling in organic materials makes IETS a highly interface-sensitive characterization tool compared to other spectroscopic methods such as Raman and infrared (IR). Unlike Raman and IR spectroscopy, the wavelength of the probing tool (electrons) in IETS is much smaller. As a result, the selection rules, governing the symmetry of the vibrating dipoles with respect to the probing wavelength, are different in IETS and depend only on the orientation of the molecules as predicted and observed experimentally.¹³

IETS was carried out at 4.2 K using a lock-in technique, with an ac modulation of 5 mV at 495 Hz to improve the signal detection. Figure 1 shows the IETS results ($\frac{d^2I}{dV^2}$ vs V) for the HJ and the RJ. All the major peaks in the IETS plot were carefully examined for reproducibility. The computed Raman and IR spectroscopy peaks with relative intensities for single-crystal rubrene by Weinberg-Wolf *et al.*¹⁴ are also shown in Fig. 1. The IETS data were also obtained for control junctions with only Al_2O_3 barrier (no rubrene) to identify the peaks due to rubrene molecules in the barrier. The Al-phonon mode at ~ 33 mV (Ref. 15) and the Al-O stretching modes at ~ 107 mV (Ref. 16) are identified. For the HJ, the peak position and the relative intensity of the different active phonon modes are found to match well with the Raman and IR peaks obtained for the free standing rubrene single crystals, showing that the rubrene molecules are *not structurally altered* in the barrier of our junctions. However, for the RJ, strong low-energy modes with additional trap-assisted reso-

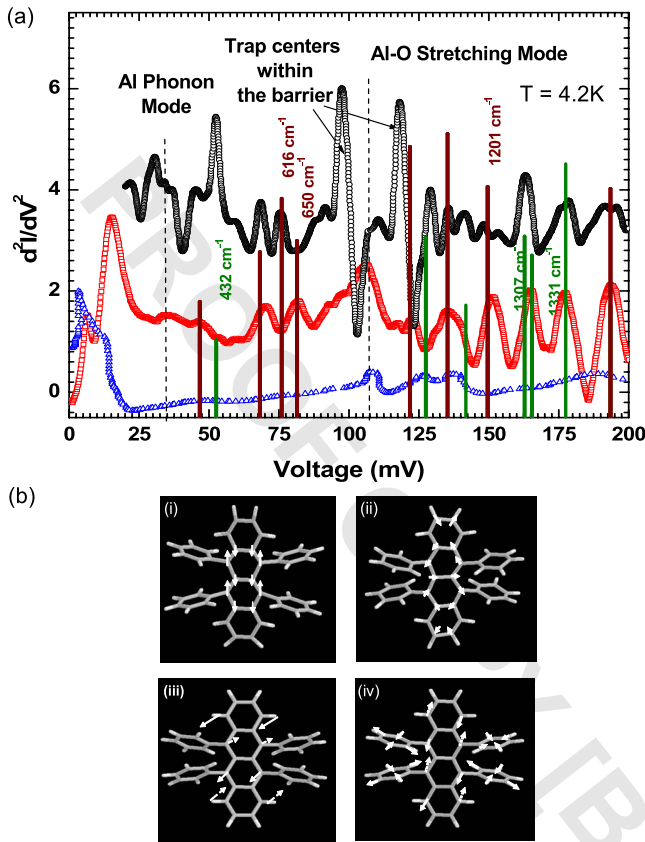


FIG. 1. (Color online) (a) IETS plots of hybrid junctions [Al(8)/Al₂O₃(0.6)/Rub(6)/Al(10)] (black circles) and rubrene junctions [Al(8)/Rub(10)/Al(10)] (red squares) with IETS plot of control junctions [Al(8)/Al₂O₃(1)/Al(8)] (blue triangles) and computed Raman (maroon line) and IR (green line) peaks for single-crystal rubrene included for reference (all thicknesses are in nm). (b) Active molecular vibrational modes observed in hybrid junctions at (i) 1201 cm⁻¹ and (ii) 650.1 cm⁻¹ (arrows represents vibrations in plane along the tetracene axis) and in rubrene junctions at (iii) 432 cm⁻¹ and (iv) 616.4 cm⁻¹ (arrows represent vibrations out of plane perpendicular to the tetracene axis). Schematics of the molecular vibration shown here is taken from Ref. 19. The IETS plots are shifted vertically for clarity.

tion modes and their relative intensities observed in the two types of junctions, the IETS data were compared with the molecular vibration simulations reported by Weinberg-Wolf *et al.*^{14,19} It is known that in IETS, the tunneling electrons interact preferably with the vibrational modes that involve oscillating bond dipoles parallel to the direction of electron flow.²⁰⁻²² In HJ, the peak observed at 81 mV, corresponding to an IR mode (650 cm⁻¹), involves oscillations along the tetracene backbone axis of the rubrene molecule. Similarly, the intense active modes at 150 mV (1201 cm⁻¹ IR mode) and 165 mV (1331 cm⁻¹ Raman mode) also show vibrations along the tetracene backbone axis [see Fig. 1(b) (i and ii)], strongly suggesting azimuthal (vertically up) growth of rubrene molecules on the alumina seed layer. In RJ, however, these modes are absent, whereas other modes at 53 mV (432 cm⁻¹ Raman mode), 76 mV (616 cm⁻¹ IR mode), and 163 mV (1307 cm⁻¹ Raman mode) are observed, which correspond to oscillations transverse to the tetracene backbone axis involving the side rings [see Fig. 1(b) (iii and iv)]. This indicates that in the latter case, the rubrene molecule prefers to grow flat on the electrode resulting in disordered growth of the film. Similar observations of different growth morphologies of OSs are reported by other techniques as well^{10,23} and may be attributed to the different electronic coupling of the organic molecules with the growth surface controlled by the surface local density of states.²⁴

Higher-energy modes at 177.5 and 193.5 mV were also seen in both the HJ and RJ, corresponding to the vibrational modes in the side phenyl rings of the rubrene molecule. Few low intensity modes with transverse oscillations are also noted in the HJ at 47 mV (377 cm⁻¹ IR mode) and 122 mV (978 cm⁻¹ IR or Raman mode), which we interpret as arising from the top rubrene-metal interface. In Fig. 1, the IETS data are shown for junctions with Al electrodes since it was found to give less background noise and help comprehend the information contained in these plots better. With ferromagnetic (FM) electrodes [Co and Py (or Fe) as the bottom and top electrodes, respectively], a large nonlinear background was present, which smear out the peaks at lower bias (<~70 mV). However, a systematic and careful study on multiple samples, both with FM and Al electrodes, showed similar activity of the molecular vibrations leading to the same conclusions.

Attempts were made to study the evolution of the growth morphology of rubrene with increasing thickness. For thin films (<10 nm), the IETS results concur with the conclusions from the cross-sectional transmission electron microscope images taken on MTJ structures.¹¹ It reproducibly showed a considerable dependence of the rubrene film thickness on the growth surface: nearly double the barrier thickness in HJ compared to RJ, for the same nominal rubrene thickness (2.2 nm read from the *in situ* quartz monitor). For thicker films (>10 nm), IETS loses the sensitivity to distinguish between the interface and bulk molecular layers. This is experimentally observed with the presence of additional second-order peaks in the IETS plot. In such cases, we have tried to study the evolution of the rubrene morphology using thickness measurement and electrical transport measurements in an attempt to separately probe the bulk and the interface properties. Thickness measurements were per-

nant states at 100 and 121 mV are observed, suggesting a disordered growth of rubrene films. Based on a previous study on trap-assisted tunneling,¹⁷ the energy level of the trap (V_t) above the electrode Fermi level and the physical position of the trap (d_t) from the bottom electrode are extracted using $V_t = V_r V_f / (V_r + V_f)$ and $d_t = d_o V_f / (V_r + V_f)$, where V_f and V_r are the position of the trap peak in forward and reverse bias, respectively, of the IETS data (reverse bias not shown in the IETS plot for clarity) and d_o is the effective electrical thickness of the barrier. A dielectric constant of 3.0 for rubrene was used in estimating d_o .¹⁸ The calculations for the trap states at 100 mV and 121 mV gave a value of $V_t = 50$ mV, $d_t = 44$ Å and $V_t = 60$ mV, $d_t = 47$ Å, respectively. However, the number of trap states and their corresponding location within the barrier were not the same from sample to sample, suggesting extrinsic origin, due to growth-related structural defects.

In order to understand the difference in the active vibra-

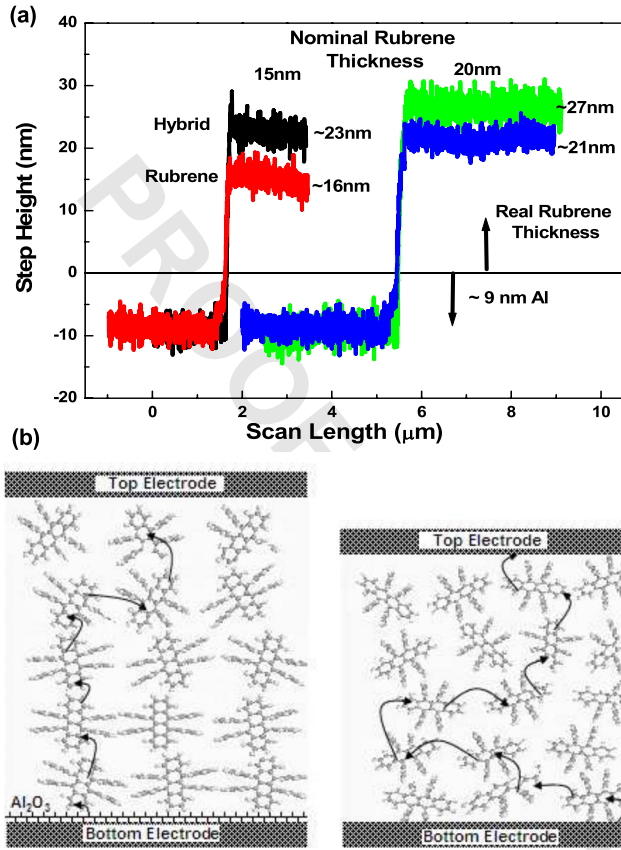


FIG. 2. (Color online) (a) Shows the rubrene film thickness measured using P-16 profilometer for Al(6 nm)/Rub(x)/Al(3 nm) and Al(6 nm)/Al₂O₃(0.7 nm)/Rub(x)/Al(3 nm) with two different values of the nominal thickness: $x=15$ and 20 nm. (b) (Left) Stronger intermolecular electronic coupling in azimuthally grown rubrene films leads to efficient spin injection and enhanced spin transport signals in hybrid junctions. (Right) Disordered nonazimuthal growth in rubrene junction leads to hopping dominant spin injection resulting in spin scattering and weak magnetotransport signals.

$G(T)$ for the HJ and the RJ at different applied electric field (F) for the nominal rubrene film thickness of 20 nm. It should be noted that the rubrene films were grown simultaneously for HJ and RJ to avoid any growth-related variation for the two cases. The charge injection model developed by Arkhipov *et al.*⁹ was used to analyze the results. Here, the injected current is found by considering injection into the Gaussian distribution of states (with variance σ) in the OS followed by either the return of the carrier to the electrode or its diffusive escape into the bulk. The injected current I_{inj} is therefore found as a product of the tunneling probability $\exp(-2\gamma_i x_0)$ (i.e., the probability of the carrier reaching the position x_0 in the first jump) and the escape probability $w_{esc}(x_0)$ (Ref. 9)

$$I_{inj} \propto \int_a^\infty dx_0 \exp(-2\gamma_i x_0) w_{esc}(x_0) \quad 209$$

$$\times \int_{-\infty}^\infty dE \text{Bol}(E) g[U(x_0) - E], \quad 210$$

where $x=a(\sim 0.6$ nm) is chosen as the surface of organic film, γ_i is the interface related inverse localization radius and $\text{Bol}(E)$ is the Boltzmann factor

$$\text{Bol}(E) = \begin{cases} \exp(-E/k_B T), & E > 0 \\ 1, & E < 0, \end{cases} \quad 214$$

k_B is the Boltzmann constant 215

and $U(x)$ is the energy barrier for injection given by $U(x) = \phi - \frac{q^2}{16\pi\epsilon_0\epsilon_r x} - qFx$, where ϕ is the energy difference between the Fermi level of the electrode and the highest occupied molecular-orbital level of rubrene, q is the electronic charge, $\epsilon_0\epsilon_r$ is the dielectric constant arising due to image forces, and F is the applied electric field. It should be noted that the inverse localization length (γ) contains information about the electronic coupling that can provide structure-related information. Furthermore, they can have different values at the interfaces (γ_i) and within the bulk (γ_b).

The injection model fits our experimental curves in the two junctions with the extracted parameters (ϕ, σ, γ_i) shown in Fig. 3. For the optimized fitting parameters, the model reproducibly matches the experimental curve for different F , supporting the validity of the fits. A large ϕ for RJ (1.03 eV) is inferred compared to HJ (0.49 eV), in agreement with previous studies of thin rubrene barrier tunnel junctions.¹¹ In addition $\gamma_i^r / \gamma_i^h \sim 10$ (r and h denote RJs and HJs, respectively) suggests the anisotropic tunneling injection efficiencies in the two junctions: better tunneling injection in HJs compared to that in RJs. This may be due to the presence of the alumina tunnel barrier and also due to the azimuthal growth of the rubrene molecules at the interface leading to a better electronic overlap of the rubrene π -electron cloud with the metal. Such effects can be expected to influence spin injection and transport. In our earlier work, related differences were observed in terms of the spin-polarized tunneling and TMR signals.¹¹

The injection model begins to deviate at low T and low F . Bulk transport,²⁵ viz., one-dimensional (1D) hopping

formed on thick rubrene films grown simultaneously on Al and Al₂O₃ surfaces with the same nominal thickness (nominal values of 15 and 20 nm), using P16 profilometer, and is shown in Fig. 2(a). A notable difference in the real thickness of the rubrene film for the two types of samples is observed. However, the difference is much less than when the films are thinner.¹¹ These results well indicate that molecular ordering is an interface effect driven by the underlying seed layer. With increasing thickness, the bulk disorder smears the preferential azimuthal growth in HJs. Nevertheless, as we will show next, we do observe some remanence of the interface ordering, which affects the transport even at 20-nm-film thickness. Figure 2(b) schematically shows a model for the rubrene layer growth and its effects on the transport properties.

Conductance versus temperature measurements [$G(T)$] were performed for thicker rubrene films and fitted well with existing transport models,^{9,25} providing information about the electronic coupling (and hence molecular ordering), both at the injection interface and within the bulk. Figure 3 shows

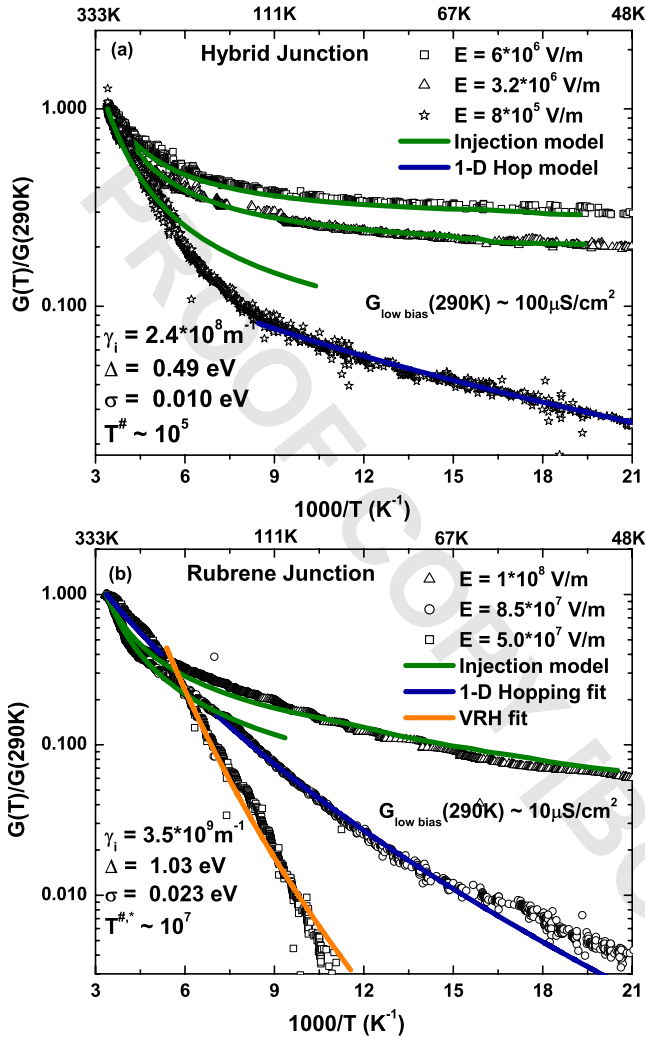


FIG. 3. (Color online) Normalized conductance (log scale) vs $1/T$ plotted for (a) hybrid-Co(8)/Al₂O₃(0.6)/Rub(40)/Fe(8) and (b) rubrene Co(8)/Rub(40)/Fe(8) junctions (thicknesses in nm). The charge injection model is fitted to the experimental curves with the extracted parameters shown. Better fits are obtained from bulk transport models for smaller F at low T .

246 $\{G(T) \propto \exp[-(T^{\#}/T)^{-1/2}]\}$ and variable range hopping (VRH)
 247 $\{G(T) \propto \exp[-(T^{\#}/T)^{-1/4}]\}$, where $T^{\#,*} \propto \gamma_b$ (bulk-related in-
 248 verse localization radius), were instead fitted under these
 249 conditions, showing a gradual change from charge injection
 250 to the bulk transport-limited regime. At such low bias and
 251 temperature, a constant density of states near the Fermi level
 252 in the organic film is assumed to contribute to bulk conduc-
 253 tion. A change from 1D hopping to VRH hopping was ob-
 254 served in RJ at lower F . In contrast, no sign of such strong
 255 temperature dependence of G was noted in HJ. Only at low
 256 electric fields ($F < \sim 1 \times 10^6$ V/m) and low temperatures
 257 was the 1D hopping model found to fit the curve for HJ. The
 258 fit is shown for the lowest measurable value of F (8
 259 $\times 10^5$ V/m). The relatively stronger temperature depen-
 260 dence of G observed in RJ compared to HJ suggests the
 261 highly disordered growth of rubrene molecules (or weaker
 262 electronic coupling) in our RJs. This is supported by the
 263 inequality $\gamma_b^i > \gamma_b^h(T^{\#,*} \propto \alpha \gamma_b)$ obtained from the parameters

$T^{\#,*}$, extracted using bulk models, signifying stronger inter- 264
 molecular coupling in HJs. These results clearly show that 265
 the bottom seed layer (Al₂O₃ in our case) plays an important 266
 role for efficient spin injection by influencing the growth of 267
 rubrene molecules at the interface. Further, the results sug- 268
 gest some remanence of this ordering into the bulk (up to 20 269
 nm in this case), providing efficient spin transport. 270

The interface magnetization was probed by PNR mea- 271
 surements using the NG1 reflectometer at NIST. Large area 272
 samples (~ 1.1 cm²) with a structure similar to the junctions 273
 used for transport studies, with Co and Fe/CoO as the bottom 274
 and top layers, were prepared on unetched Si substrates. The 275
 nominal thickness of the rubrene film was 10 nm and 20 nm 276
 for the hybrid and the rubrene samples, respectively. The 277
 samples were cooled down in a magnetic field of 0.7 T to 278
 achieve exchange pinning of the Fe layer at the Fe/CoO in- 279
 terface. Using a supermirror polarizer and analyzer, the neu- 280
 tron beam was polarized parallel to the magnetic field, which 281
 was applied in the sample plane, as described in Ref. 26. The 282
 reflectivity data were corrected for beam footprint, instru- 283
 ment background, and efficiencies of the polarizing elements 284
 (typically $> 97\%$). Four reflectivity cross sections were mea- 285
 sured: R^{++} and R^{--} labeled nonspin flip (NSF) as the neu- 286
 tron retains its original polarization after scattering from the 287
 sample, and R^{+-} and R^{-+} , labeled spin flip (SF), where the 288
 neutron spin flips its polarization, from the up (+) to down 289
 state (−) and vice versa, upon scattering. The nuclear scatter- 290
 ing length density (SLD) of a material or chemical SLD 291
 (ρ_{chem}) can be determined from fits to the NSF reflectivity 292
 data^{26–28} in order to extract a profile of the chemical compo- 293
 sition of the film as a function of depth. In addition, the 294
 vector magnetization of the film as a function of depth can be 295
 ascertained from simultaneous fits to the NSF and SF cross 296
 sections. Specifically, the splitting between the NSF reflect- 297
 ivity cross sections is sensitive to the component of the mag- 298
 netization parallel to the applied field. The SF reflectivity 299
 is entirely of magnetic origin and is sensitive only to the 300
 component of the magnetization perpendicular to the applied 301
 field. The NSF PNR data were fit²⁹ with the REFLPAK (Ref. 302
 30) and GAREFL (Ref. 31) software suites to obtain the 303
 chemical and magnetic depth profiles. While spin-flip scatter- 304
 ing was measured at all fields considered in this study, the 305
 scattering was observed to be negligible (data not shown), 306
 indicating no significant moment perpendicular to the ap- 307
 plied field. 308

The reflectivity data collected at 5 K confirmed expecta- 309
 tions from SQUID magnetometry that the two FM layer mag- 310
 netizations are aligned parallel (P) in high fields (H_a 311
 = 0.7 T) and antiparallel (AP) in low fields (H_a = 10 mT). 312
 Figure 4 shows the NSF reflectivity measurement (R^{++} and 313
 R^{--}) for both the rubrene and the hybrid sample at H_a 314
 = 0.7 T, along with the corresponding depth profile of the 315
 nuclear SLD and the layer magnetic moment for the two 316
 samples obtained from the fit to the reflectivity data. The 317
 most significant difference between the samples includes a 318
 lower value of the rubrene nuclear SLD and a larger value of 319
 the rubrene layer thickness (~ 1.5 times the nominal thick- 320
 ness) obtained for the hybrid sample relative to the rubrene 321
 sample (Fig. 4). This result can be explained by the different 322
 morphology and packing density of the rubrene molecules 323

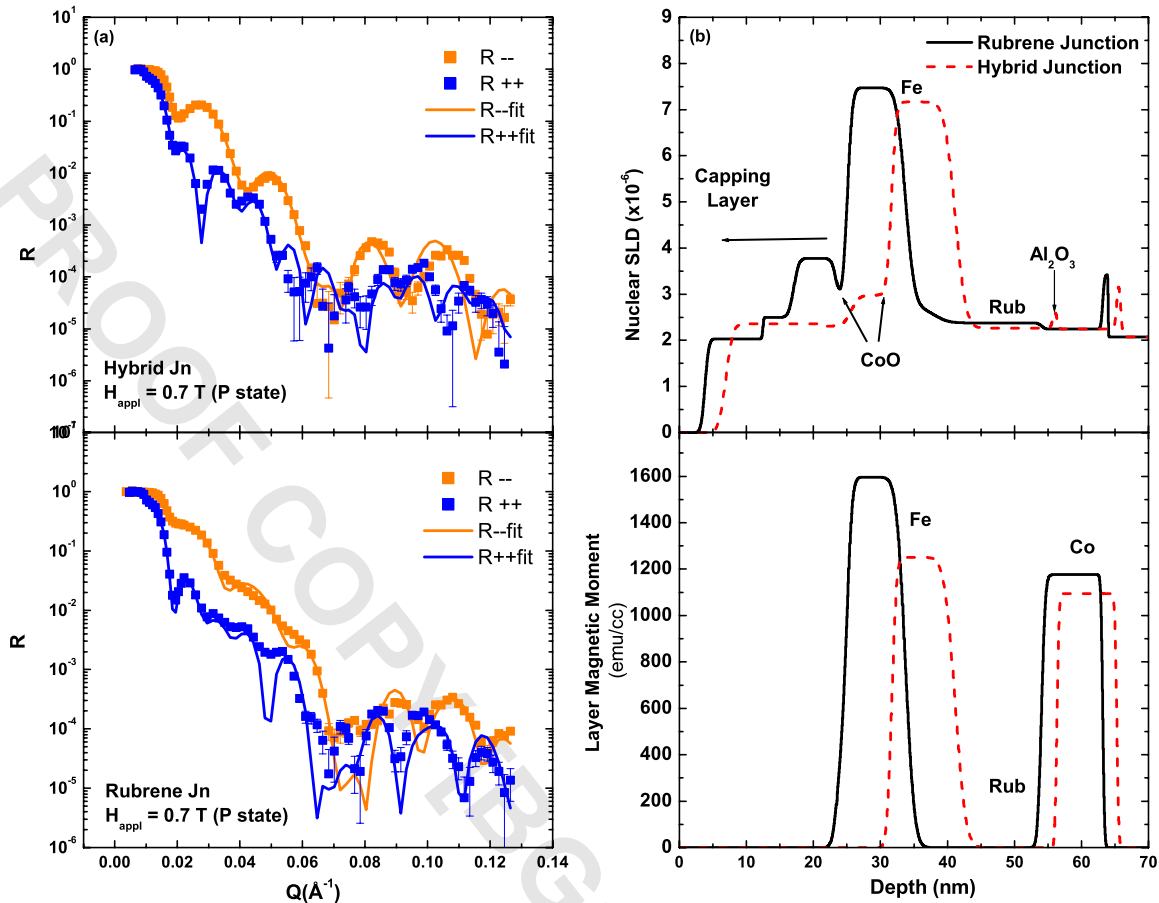


FIG. 4. (Color online) (a) Measured NSF reflectivity data ($R++$ and $R--$) and the corresponding fits for both the rubrene and hybrid samples at $H_a=0.7$ T. (b) Depth profile of the nuclear SLD (top) and the layer magnetic moment (bottom) obtained from the PNR fits for the hybrid: Si/SiO(1)/Co(8)/Al₂O₃(0.6)/Rub(15)/Fe(8)/CoO(1.5) and rubrene: Si/SiO(1)/Co(8)/Rub(20)/Fe(8)/CoO(1.5) samples.

324 (Fig. 2) grown on different seed layers (i.e., Co or Al₂O₃), as
 325 described earlier. It is important to note, however, that the
 326 structural characteristics of the underlying Co layer in both
 327 samples, as determined from PNR, are similar. Specifically,
 328 the structural roughness (i.e., corresponding to the width of
 329 the interface between the Co layer and the layer above) at the
 330 Co/rubrene and Co/Al₂O₃ interfaces in rubrene and hybrid
 331 samples, respectively, is comparable in both samples (Fig. 4).
 332 Similar magnetic moments (~ 1100 emu/cc) for the free
 333 bottom Co layer were also observed in the P and AP states of
 334 the hybrid and the rubrene sample. We thus conclude that
 335 there is minimal in-plane magnetic domain formation in the
 336 bottom FM electrode in the P and AP states because the
 337 structural disorder within the Co layer is limited.

338 In general, the moments for all the FM layers in both
 339 samples were found to be lower than the bulk values (Co-
 340 1422 emu/cc and Fe-1700 emu/cc), which is consistent with
 341 expectations for fine-grained polycrystalline thin FM layers
 342 and more so for the top FM layers with additional interfacial
 343 disorder. The average magnetic moment of the top Fe layer
 344 in the hybrid sample is considerably lower, by $\sim 20\%$ for
 345 both the AP and P states, compared to the average Fe mo-
 346 ment in the rubrene sample (Fig. 4). This difference although
 347 puzzling is an interesting result and requires careful interpre-
 348 tation within the context of the corresponding structural mor-

349 phology of the upper layers in the two samples. First, it is
 350 unlikely that oxidation of the Fe is the source for the reduced
 351 moment in the hybrid structure because the samples were
 352 well protected with a thick bilayer of Al(7 nm)/
 353 Al₂O₃(5 nm) over it (Fig. 4). The nuclear SLD of the CoO
 354 layer adjacent to the Fe was found to be lower than the bulk
 355 value ($\sim 4.27 \times 10^{-6} \text{ \AA}^{-2}$) in the hybrid sample, suggesting a
 356 reduced structural density of the upper layers rather than en-
 357 hanced oxidation. Another possibility is that the reduced Fe
 358 moment is a direct consequence of higher roughness of the
 359 rubrene layer in hybrid structure. However, the PNR fitting
 360 analysis showed that the roughness of the rubrene/Fe layer is
 361 similar (~ 3 nm) in the two samples though there exists a
 362 higher roughness at the top interface of the Fe layer in the
 363 hybrid sample (~ 1.3 nm) compared to in rubrene sample (
 364 ~ 0.7 nm).

365 A more significant finding is that the nuclear SLD for Fe
 366 is lower in the hybrid sample (Fig. 4) presumably indicating
 367 that the structural density is reduced from that of bulk Fe. A
 368 possible origin of this reduction emerges from an under-
 369 standing of the growth of Fe at the first few layers, which can
 370 be directly influenced by the structural properties of the un-
 371 derlying rubrene layer. In the hybrid sample, the lower den-
 372 sity of Fe follows from the lower packing density of the
 373 underlying rubrene layer, which leads in turn to the higher

374 Fe/CoO interface roughness. Given the roughness of the
 375 rubrene/Fe interface, the presence of subnanofilamentary
 376 growth of Fe at this interface is probable in both samples.
 377 Due to the lower packing density and the azimuthal growth
 378 of rubrene molecules in hybrid structure, we can expect such
 379 formations to be more common in these hybrid samples. The
 380 structural properties of the top Fe electrode in hybrid
 381 samples clearly affect its magnetic response and are respon-
 382 sible for the reduced moment. Also, the higher interface
 383 roughness of the top Fe layer in the hybrid structure will
 384 have a direct influence on the exchange coupling and tend to
 385 weaken the pinning of the Fe layer. Correspondingly, the
 386 magnetic response of the Fe filaments at the Fe/Rubrene in-
 387 terface may presumably differ from those in the center of the
 388 layer. This will require a careful and systematic study that
 389 will be followed in the future.

390 The weak exchange pinning of such formations at the
 391 rubrene/Fe interface in HJ may lead to random spin fluctua-
 392 tions that are detrimental for spin injection and transport. A
 393 way to tailor this effect was to modify our junction stack. We
 394 decided to exchange bias the bottom smooth Co layer and
 395 made the top rough Fe layer free. MR measurements were
 396 performed for the HJs with a rubrene thickness of 25 nm
 397 (shown in Fig. 5). A MR of 7% was observed at 4.2 K,
 398 reducing to $\sim 4.5\%$ at 77 K. No MR was noticed at room
 399 temperature. A sharp switching between the parallel and the
 400 antiparallel states are noted, suggesting the advantage of hav-
 401 ing a strongly exchange pinned Co layer and a free top Fe
 402 layer. The gradual decrease in MR with bias at 77 K (see Fig.
 403 5 inset) indicated the good quality of the junctions. Further,
 404 we were able to detect spin transport signals through thicker
 405 rubrene films (~ 25 nm), hinting at a significant improve-
 406 ment in our device performance. In comparison, no (or small
 407 $\sim 0.4\%$ in some cases) MR was measured even in the most
 408 stable thin rubrene barrier junctions (5 nm), confirming the
 409 strong influence of interface ordering on spin injection.

410 In conclusion, we have observed the influence of the seed
 411 layer on the growth morphology of the rubrene molecules at

424
 425
 426

427 *vkarthik@mit.edu

428 ¹W. J. M. Naber, S. Faez, and W. G. van der Wiel, *J. Phys. D* **40**,
 429 R205 (2007).

430 ²Z. H. Xiong, Z. Di Wu, Valy Vardeny, and Jing Shi, *Nature*
 431 (London) **427**, 821 (2004).

432 ³T. S. Santos, J. S. Lee, P. Migdal, I. C. Lekshmi, B. Satpati, and
 433 J. S. Moodera, *Phys. Rev. Lett.* **98**, 016601 (2007).

434 ⁴V. Dediu, L. E. Hueso, I. Bergenti, A. Riminucci, F. Borgatti, P.
 435 Graziosi, C. Newby, F. Casoli, M. P. De Jong, C. Taliani, and Y.
 436 Zhan, *Phys. Rev. B* **78**, 115203 (2008).

AQ: #36
 3 437 ⁵V. N. Prigodin, N. P. Raju, K. I. Pokhodnya, J. S. Miller, and A.
 438 J. Epstein, *Adv. Mater.* **14**, 1230 (2002).

439 ⁶Ö. Mermer, G. Veeraraghavan, T. L. Francis, Y. Sheng, D. T.
 440 Nguyen, M. Wohlgenannt, A. Köhler, M. K. Al-Suti, and M. S.
 441 Khan, *Phys. Rev. B* **72**, 205202 (2005).

442 ⁷V. Coropceanu, J. Cornil, D. A. da Silvo Filho, Y. Olivier, R.
 443 Silbey, and J.-L. Bre'das, *Chem. Rev. (Washington, D.C.)* **107**,

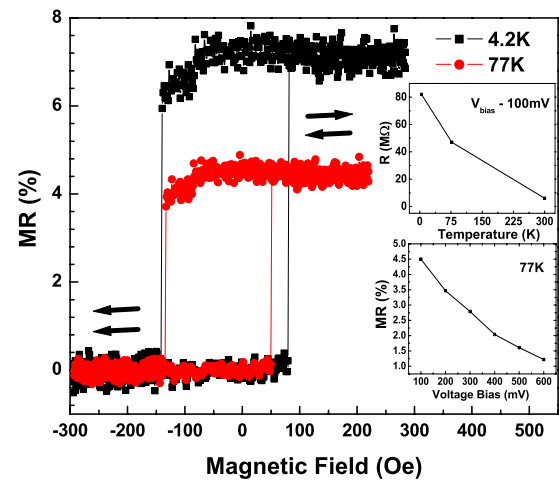


FIG. 5. (Color online) MR measurement (minor loop) per-
 formed on hybrid junction: CoO(1)/Co(8)/Al₂O₃(0.6)/
 Rub(25 nm)/Fe(12) at 77 and 4.2 K. The bottom Co electrode is
 pinned to the CoO layer by cooling the sample in negative field.
 Insets: top shows the increase in junction resistance with cool down
 and the bottom shows the gradual decrease in MR with applied bias
 at 77 K. The shift in the curve (toward left) is due to a residual
 current from the power supply, flowing through the magnet.

the interface. Different growth mechanisms lead to a highly
 anisotropic conduction mechanism that affects both charge
 and spin injection and transport properties. Although this
 study reveals better spin transport in molecularly ordered
 films, PNR result shows a corresponding complex nature of
 interface magnetic behavior, highlighting the open chal-
 lenges that have to be carefully addressed and tailored if
 organic materials are to reach their theoretical expectations
 in spintronics application.

This work was supported by the KIST-MIT program
 funds, the ONR Grant No. N00014-09-1-0177, and the NSF
 Grant No. DMR-0504158.

926 (2007). 444

⁸M. A. Baldo and S. R. Forrest, *Phys. Rev. B* **64**, 085201 (2001). 445

⁹V. I. Arkhipov, E. V. Emelianova, Y. H. Tak, and H. Bässler, *J.*
Appl. Phys. **84**, 848 (1998). 446

¹⁰S. C. B. Mannsfeld, A. Virkar, C. Reese, M. F. Toney, and Z.
 Bao, *Adv. Mater.* **21**, 2294 (2009). 448

¹¹J. H. Shim, K. V. Raman, Y. J. Park, T. S. Santos, G. X. Miao, B.
 Satpati, and J. S. Moodera, *Phys. Rev. Lett.* **100**, 226603 (2008). 450

¹²R. C. Jaklevic and J. Lambe, *Phys. Rev. Lett.* **17**, 1139 (1966); J.
 Lambe and R. C. Jaklevic, *Phys. Rev.* **165**, 821 (1968). 452

¹³P. K. Hansma, *Tunneling Spectroscopy: Capabilities, Application*
and New Techniques (Plenum Press, New York, 1982). 454

¹⁴J. R. Weinberg-Wolf, L. E. McNeil, S. Liu, and C. Kloc, *J. Phys.:*
Condens. Matter **19**, 276204 (2007). 456

¹⁵A. L. Geiger, B. S. Chandrashekar, and J. G. Adler, *Phys. Rev.*
188, 1130 (1969). 458

¹⁶D. C. Tsui, R. E. Dietz, and L. R. Walker, *Phys. Rev. Lett.* **27**, 460

- 461 1729 (1971).
- 462 ¹⁷M. Wang, W. He, and T. P. Ma, *Appl. Phys. Lett.* **86**, 192113
463 (2005).
- 464 ¹⁸S. Fratini, H. Xie, I. N. Hulea, S. Ciuchi, and A. F. Morpurgo,
465 *New J. Phys.* **10**, 033031 (2008).
- 466 ¹⁹<http://www.physics.unc.edu/project/mcneil/MolecularAnimations/>
467 [anim.php](http://www.physics.unc.edu/project/mcneil/MolecularAnimations/anim.php)
- 468 ²⁰J. Kirtley, D. J. Scalapino, and P. K. Hansma, *Phys. Rev. B* **14**,
469 3177 (1976).
- 470 ²¹N. M. D. Brown, R. B. Floyd, and D. G. Walmsley, *J. Chem.*
471 *Soc., Faraday Trans. 2* **75**, 17 (1979); N. M. D. Brown, W. J.
472 Nelson, and D. G. Walmsley, *ibid.* **75**, 32 (1979).
- AQ: #73 ²²J. T. Hall and P. K. Hansma, *Surf. Sci.* **77**, 61 (1978).
- 5 474 ²³R. J. Kline, M. D. McGehee, and M. F. Toney, *Nature Mater.* **5**,
475 222 (2006).
- ²⁴G. E. Thayer, J. T. Sadowski, F. Meyer zu Heringdorf, T. Sakurai, and R. M. Tromp, *Phys. Rev. Lett.* **95**, 256106 (2005). 476
- ²⁵N. F. Mott, *Philos. Mag.* **19**, 835 (1969). 478
- ²⁶G. P. Felcher, *Phys. Rev. B* **24**, 1595 (1981). 479 AQ
- ²⁷M. R. Fitzsimmons and C. F. Majkrzak, *Modern Techniques for* 480 #6
Characterizing Magnetic Materials (Kluwer, Norwell, MA, 481
2005). 482
- ²⁸K. V. O. Donovan and N. F. Berk, *Neutron Scattering from Magnetic* 483
Materials (Elsevier, Amsterdam, The Netherlands). 484
- ²⁹C. F. Majkrzak, *Physica B* **221**, 342 (1996). 485
- ³⁰P. A. Kienzle, K. V. O'Donovan, J. F. Ankner, N. F. Berk, and C. 486
F. Majkrzak, <http://www.ncnr.nist.gov/reflpak> (2000–2006). 487
- ³¹P. A. Kienzle, M. Doucet, D. J. McGillivray, K. V. O'Donovan, 488
N. F. Berk, and C. F. Majkrzak, <http://www.ncnr.nist.gov/reflpak> 489
(2000–2006). 490

AUTHOR QUERIES —

- #1 AU: Please supply definition for “MTJ” if possible.
- #2 AU: Although a caption makes reference to color online, Fig. 1 will appear black and white in print. Please make sure the caption makes sense to print reader.
- #3 AU: Please check the supplied authors names for et al references.
- #4 Au: Please verify that the first page should be '2294' not '1' in Ref. 10.
- #5 Au: Please verify that the volume should be '77' not '76' in Ref. 22.
- #6 Au: Please verify that the first page should be '1595' not 'R1595' in Ref. 26.

PROOF COPY [BG11589] 082943PRB